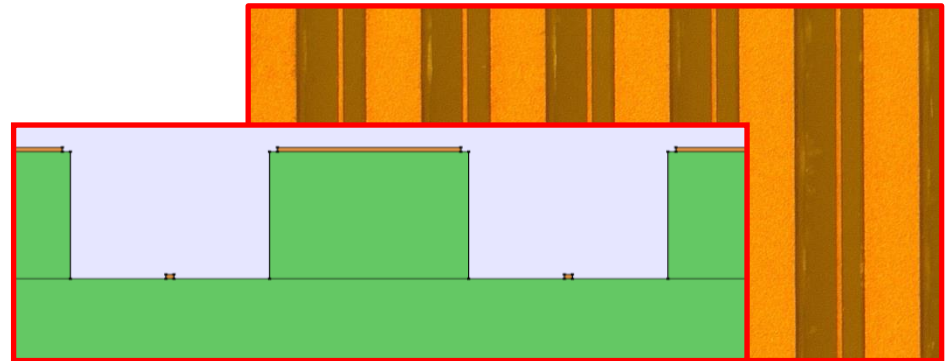
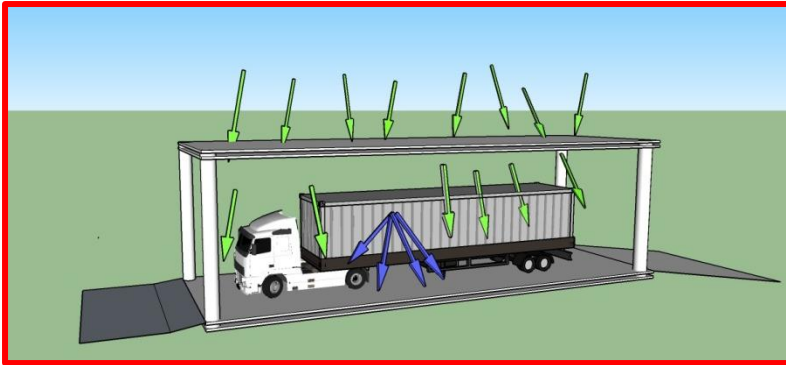


Status of Thick-groove detector



Silvia Franchino (on behalf of the Micro-Pattern Technology workshop)²
Michela Biglietti¹, Vincenzo Canale³, Rui de Oliveira², Paolo Iengo^{2,3},
Mauro Iodice¹, Stefano Mastroianni³, Fabrizio Petrucci^{1,4}

¹ INFN Roma3, ² CERN, ³ INFN Napoli, ⁴ Università Roma 3

15th RD51 Collaboration Meeting
CERN, 18th March 2015

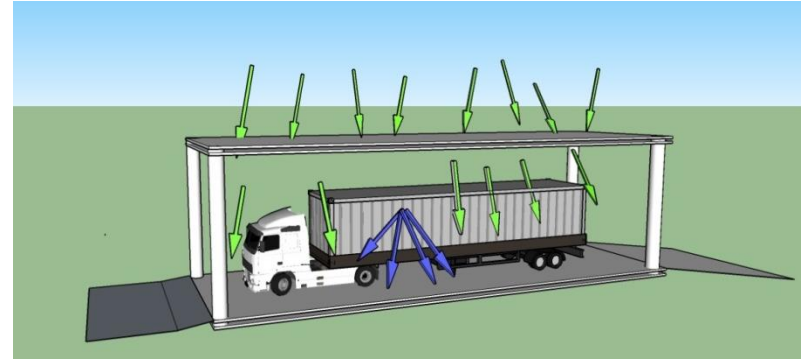
Outline

- Introduction
- Construction procedure
- First (very preliminary) results
- Future plans

The idea

Application: Muon tomography, homeland security

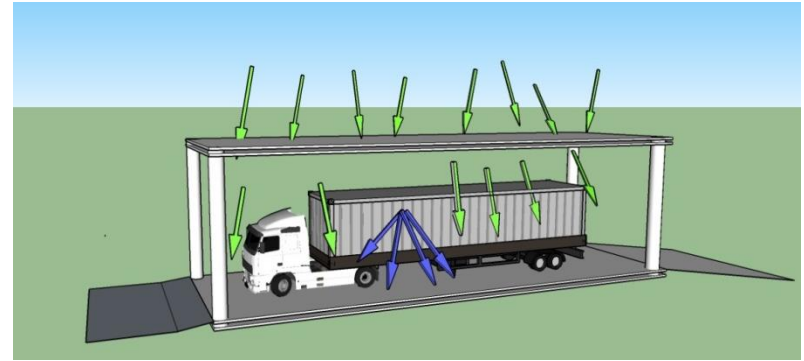
- Simple construction (compatible with industrial mass production)
- Reduced operation costs
- Compact scanning station (even curved shape to increase angular coverage)
- Limited rate capability
- Single layer space resolution ~ 500 μm



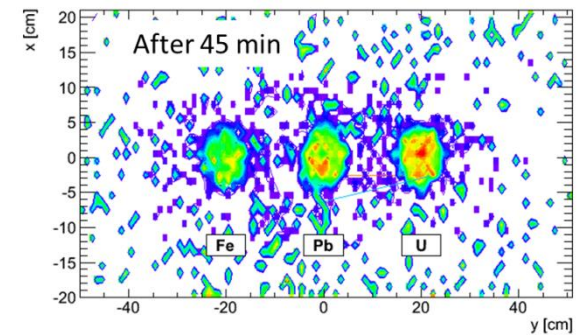
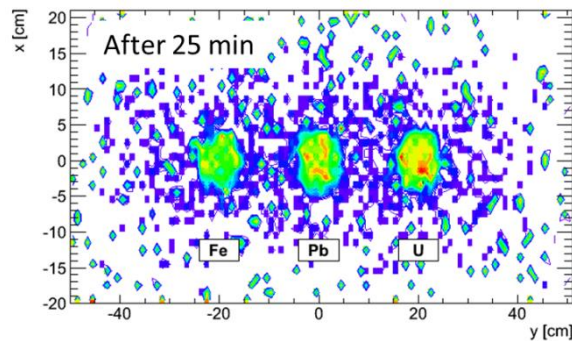
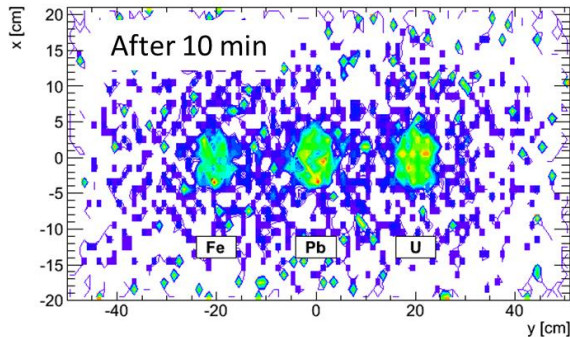
The idea

Application: Muon tomography, homeland security

- Simple construction (compatible with industrial mass production)
- Reduced operation costs
- Compact scanning station (even curved shape to increase angular coverage)
- Limited rate capability
- Single layer space resolution $\sim 500 \mu\text{m}$



GEANT 4 simulation: Reconstruction of 4 cm-diameter spheres of Fe, Pb and U with the expected performance of a scanning station based on thick-Groove detector ($500 \mu\text{m}$ spatial resolution, 3 mrad angular resolution).

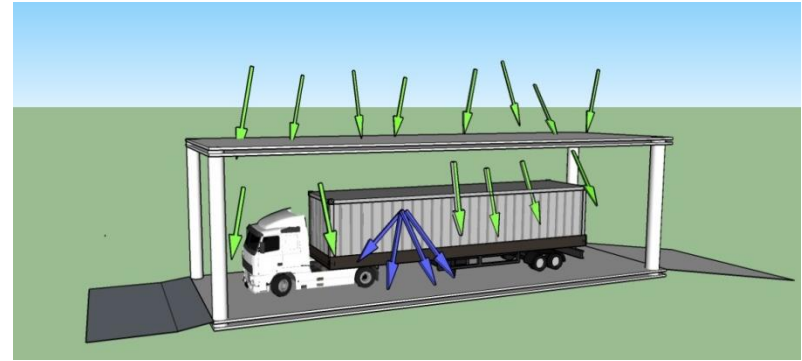


This idea has been already used with other detectors, e.g. K. Gnanvo et al, "Detection and Imaging of High-Z Materials with a Muon Tomography Station Using GEM Detectors" RD51-Note-2010-004

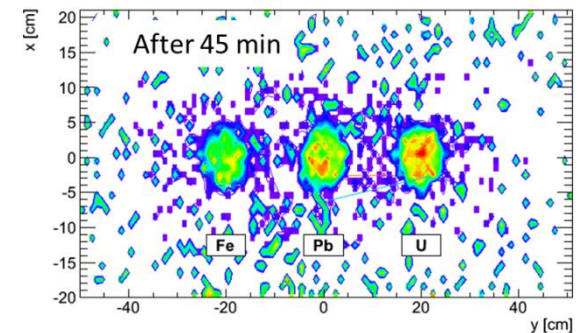
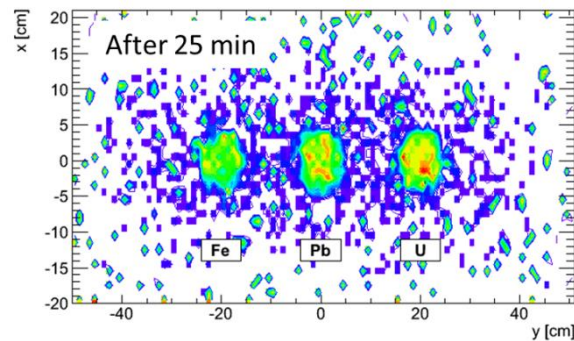
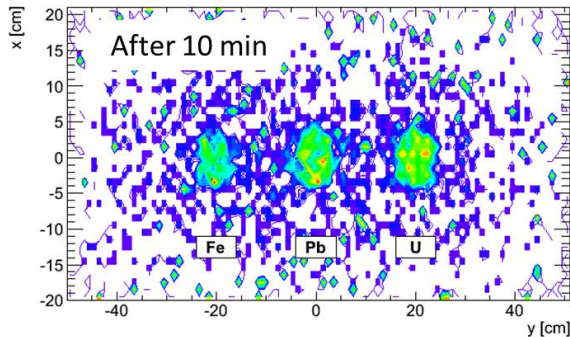
The idea

Application: Muon tomography, homeland security

- Simple construction (compatible with industrial mass production)
- Reduced operation costs
- Compact scanning station (even curved shape to increase angular coverage)
- Limited rate capability
- Single layer space resolution $\sim 500 \mu\text{m}$



GEANT 4 simulation: Reconstruction of 4 cm-diameter spheres of Fe, Pb and U with the expected performance of a scanning station based on thick-Groove detector ($500 \mu\text{m}$ spatial resolution, 3 mrad angular resolution).

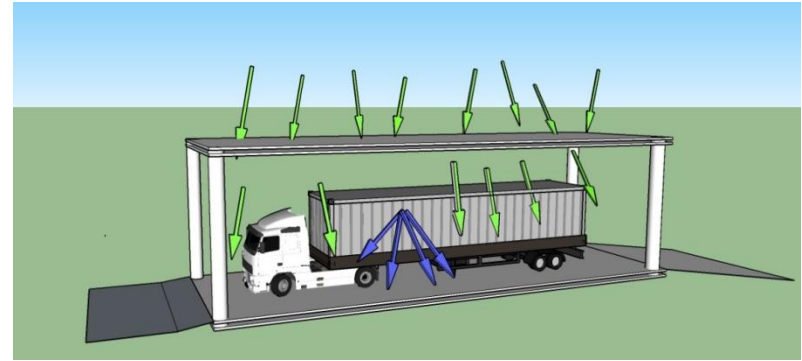


This idea has been already used with other detectors, e.g. K. Gnanvo et al, "Detection and Imaging of High-Z Materials with a Muon Tomography Station Using GEM Detectors" RD51-Note-2010-004

The idea

Application: Muon tomography, homeland security

- Simple construction
- Limited rate capability
- Single layer space resolution ~ 500 μm
- Self-triggering capability



Structure like the Micro-groove detector but bigger scale



ELSEVIER Nuclear Instruments and Methods in Physics Research A 424 (1999) 444–458

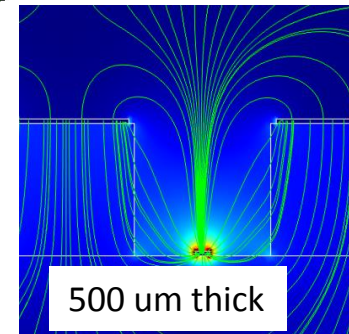
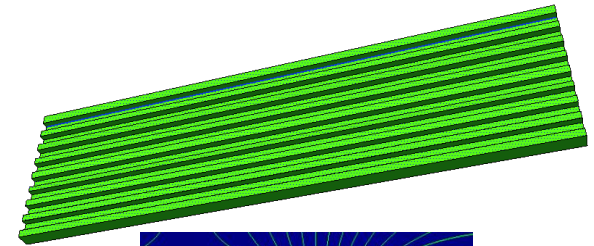
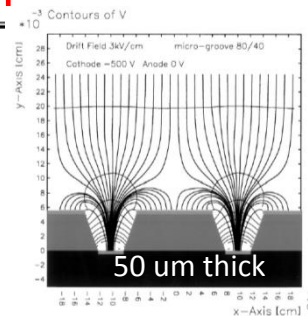
NUCLEAR INSTRUMENTS & METHODS IN PHYSICS RESEARCH
Section A

The micro-groove detector¹

R. Bellazzini^{a,b,*}, M. Bozzo^c, A. Brez^a, G. Gariano^a, L. Latronico^a, N. Lumb^a,
A. Papanestis^a, G. Spandre^a, M.M. Massai^a, R. Raffo^a, M.A. Spezziga^a

^a INFN-Pisa and University of Pisa, Pisa, Italy
^b CERN, CH-1211 Geneva 23, Switzerland
^c INFN-Genova and University of Genova, Genova, Italy

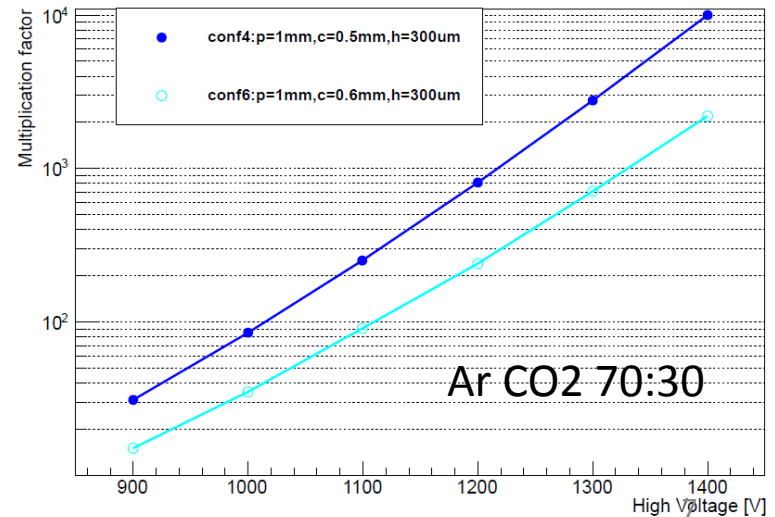
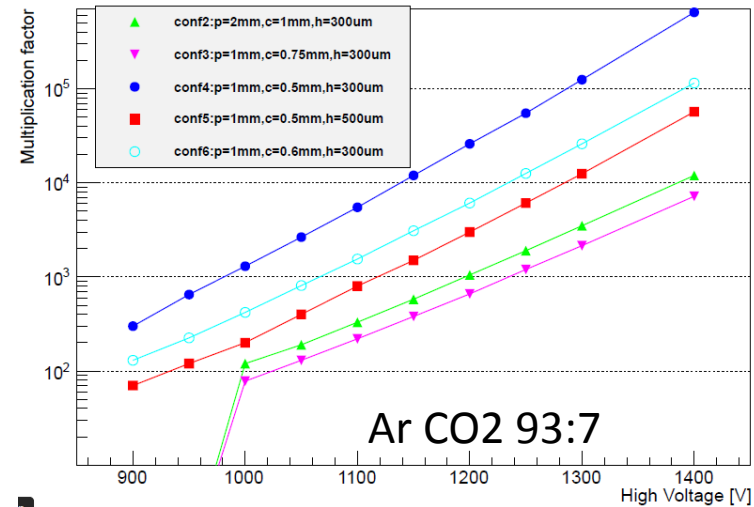
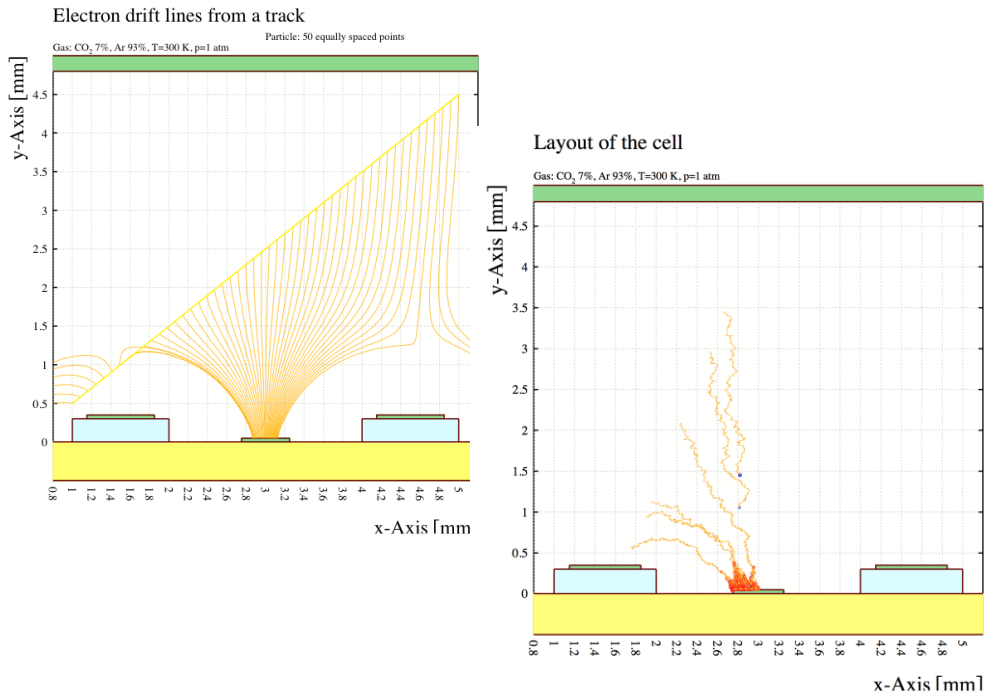
Received 28 May 1998



- Exactly like Thick GEM vs GEM, the thick groove should be feasible to be produced in PCB industries
- Thick groove vs MSGC: here we should have one more parameter to optimize (groove height) to fight against sparks for a given pitch

Geometry and simulation

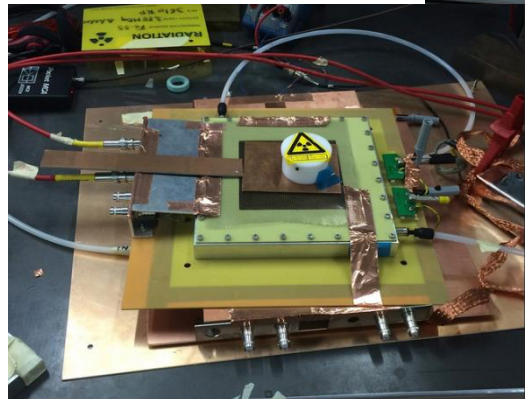
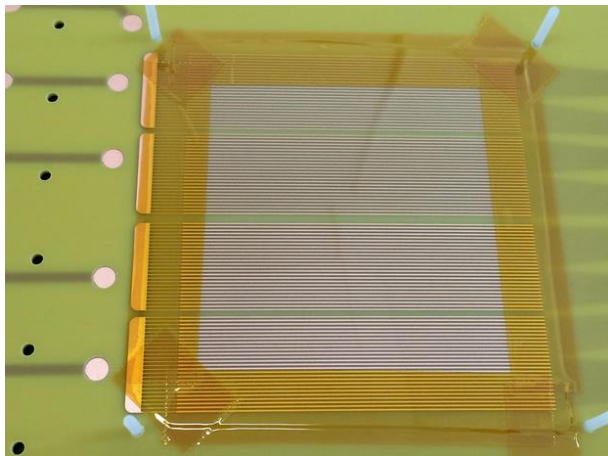
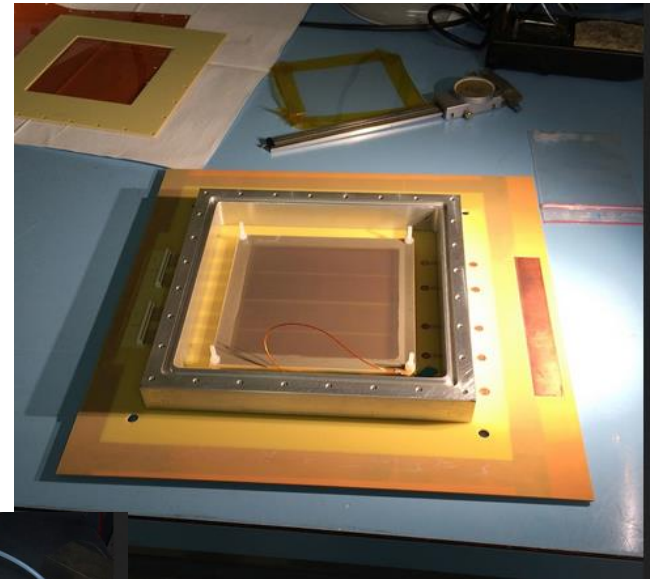
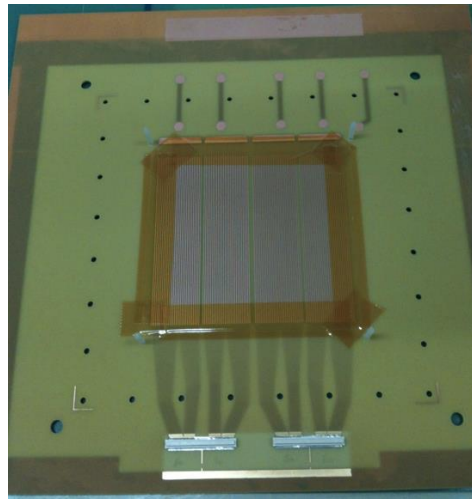
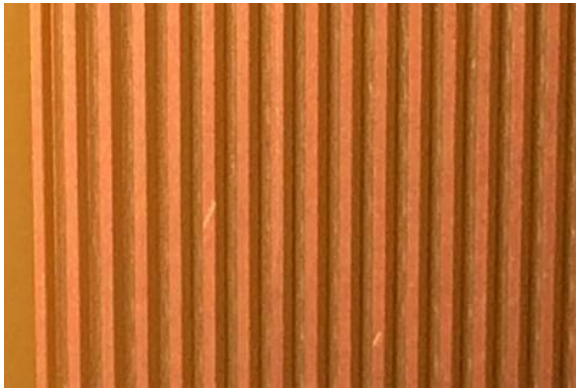
Simulations performed with garfield and comsol in order to prove the principle and optimize the geometry before construction



All simulations performed with thickness 0.3 mm,
 First prototype thick 0.5 mm (easier to be produced)

First prototype

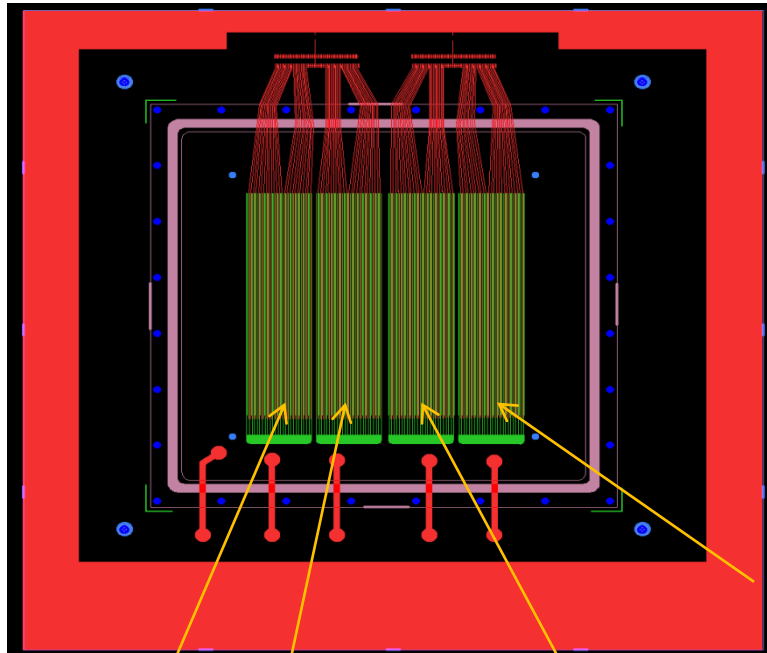
- First prototype designed and produced in the workshop (January 2015)
- 4 different detectors (active area 10 cm * 2.5 cm)
- All four detectors working (quickly tested in GDD lab) only preliminary results presented today
- We are evaluating critical points and possible improvements for next version



Design

4 independent detector in
the same gas box

Pitch 1mm



DETECTOR 4

Aperture 500 μm
Cathode 500 μm
Anode 40 μm

DETECTOR 1

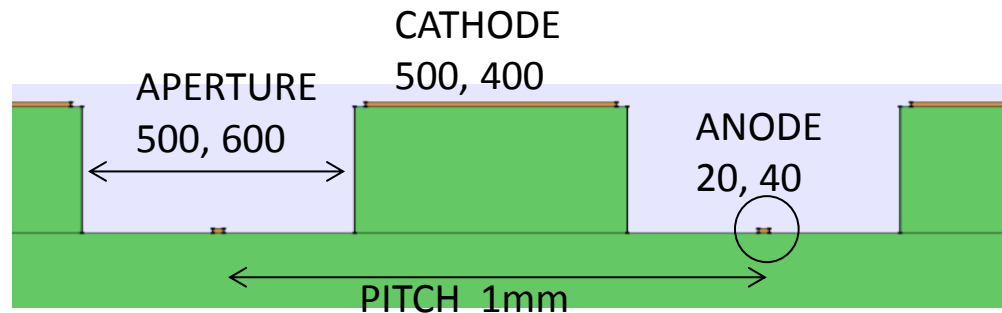
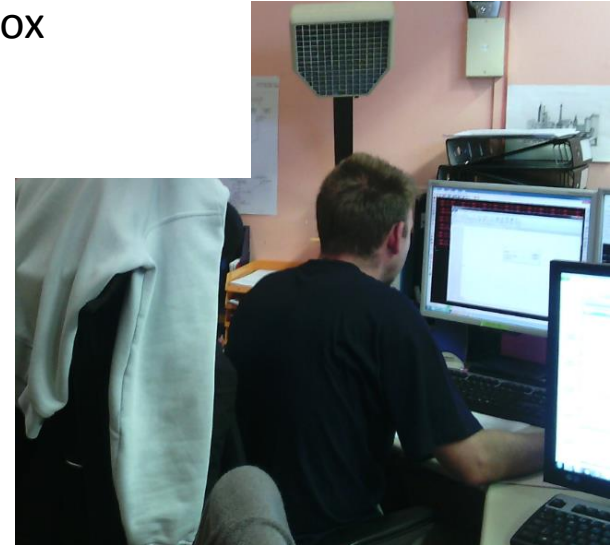
Aperture 600 μm
Cathode 400 μm
Anode 20 μm

DETECTOR 2

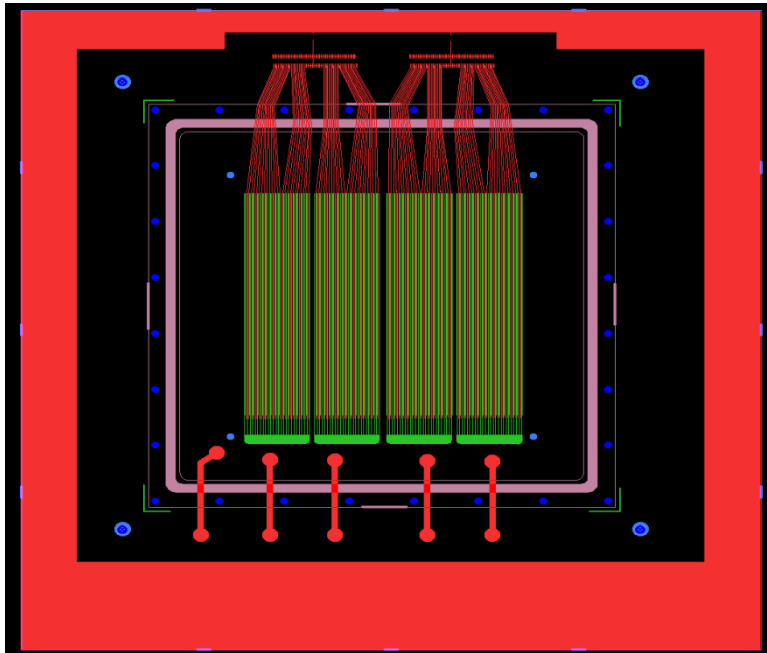
Aperture 600 μm
Cathode 400 μm
Anode 40 μm

DETECTOR 3

Aperture 500 μm
Cathode 500 μm
Anode 20 μm



Production technique

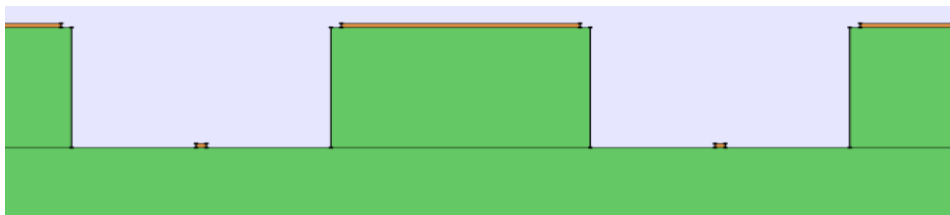


ANO
BOARD

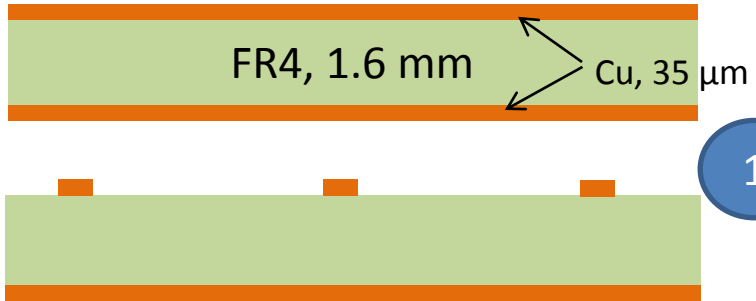
With four different designs,
Two of them reaching 20 μm
anode width

CATH
BOARD

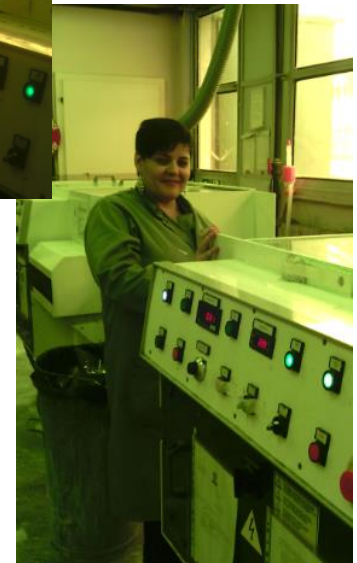
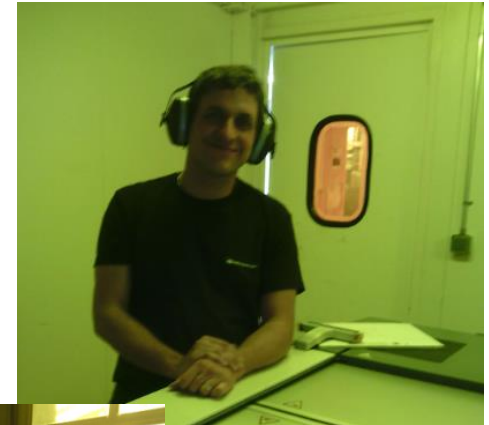
With four different designs
and fiberglass machining



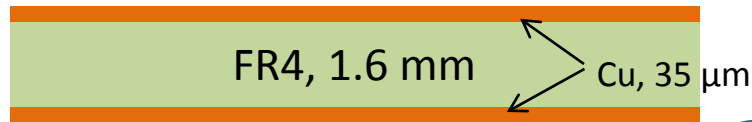
Anode board



Top face:
Standard lithography
for anode lines up to 40
um width



Anode board



1

Top face:
Standard lithography
for anode lines up to 40
 μm width



2

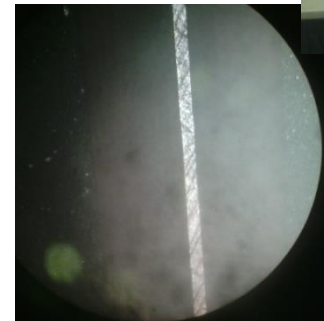
Micro-etching

To reach anode width 20 μm
Protecting the two detectors
with 40 μm anodes

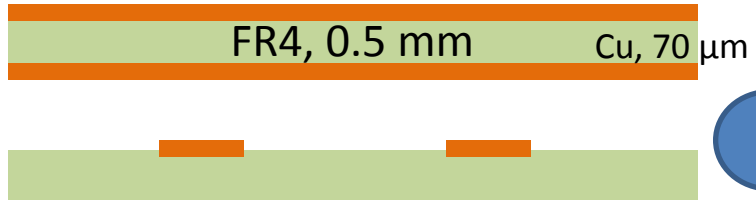
Acid Chromic
Etching ($\sim 1 \mu\text{m}/\text{min}$)



Optical control until
reaching 20 μm width

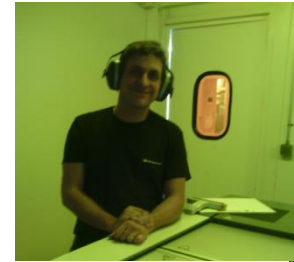


Cathode board

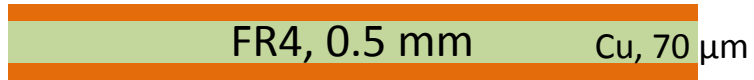


3

Top face: Standard lithography for cathode
Bot. face: full etching



Cathode board

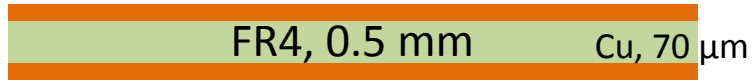


Top face: Standard lithography for cathode
Bot. face: full etching



Glue pressing
(krepel 2*25 μm)

Cathode board



Top face: Standard lithography for cathode
Bot. face: full etching



Glue pressing
(krepel 2*25 μm)



Milling of bot. face (CNC machine)



Detector completion

ANODE



CATHODE



6

Pressing anode-cathode board

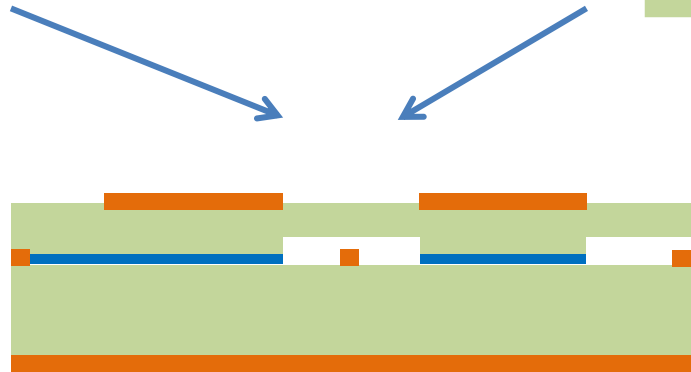


Detector completion

ANODE

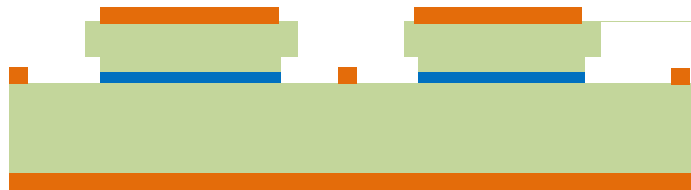


CATHODE



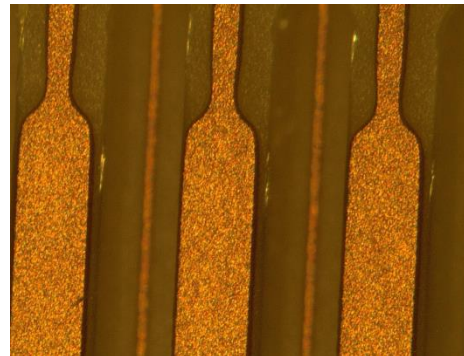
6

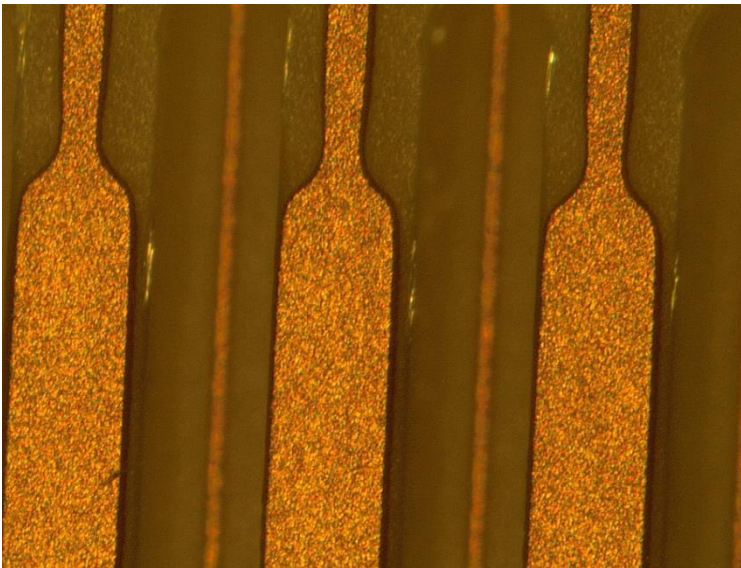
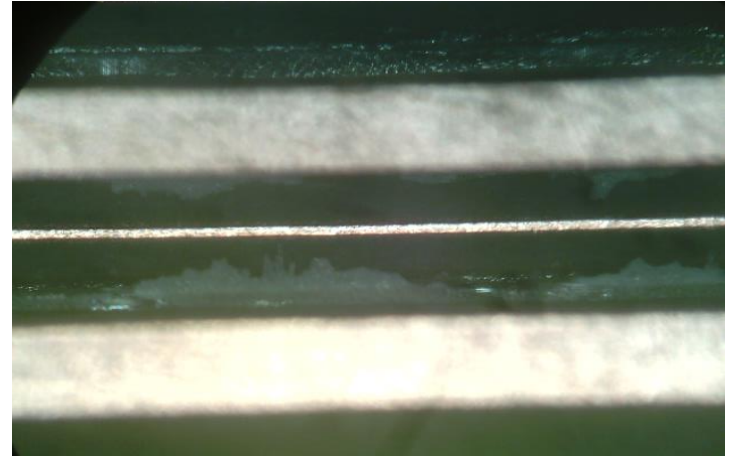
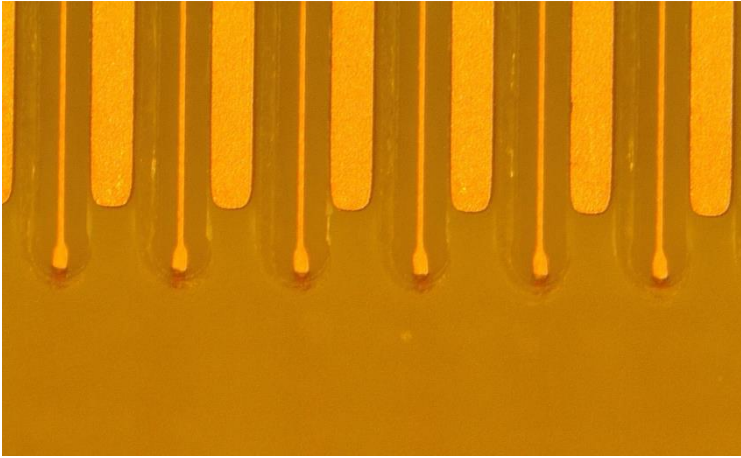
Pressing anode-cathode board



7

Milling of top face





Final cleaning and test in air

- Final cleaning with demineralized water high pressure
- Test in air. HV applied between anode and cathode

Far from Pashen curve (like Thick GEM without treatment)

probably due to machining of fiber glass

Theoretically should spark in air @ 3kV

Each of the four spark @ ~ 2.1 kV

Sparks not coming from the same spot

- Tried performance of detector in gas without additional treatment (easiest way compatible with industrial production)

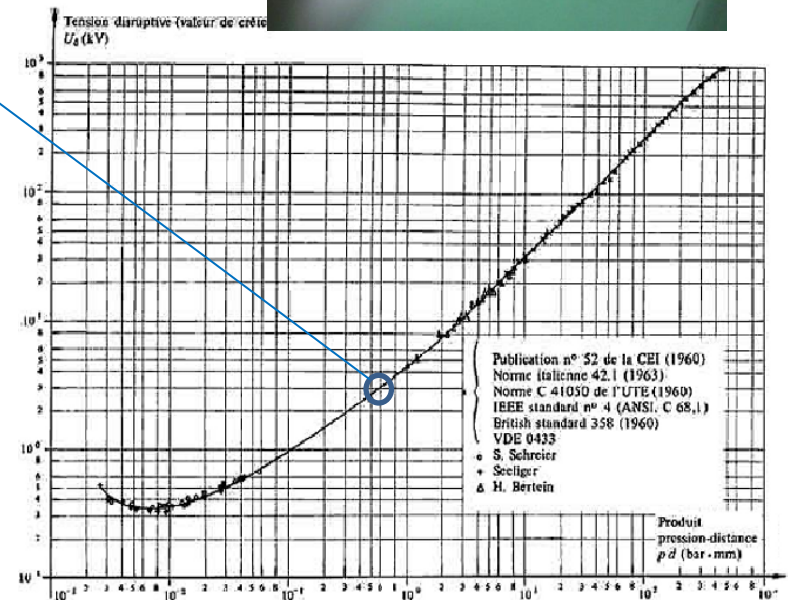


Fig. 9.1.1 Courbe de Paschen pour l'air en échelles logarithmiques. Température 20°C [262].

We could improve it:

- rim on cathode electrodes
- Chemical treatment of machined fiber glass (e.g. permanganate, hydrofluoric acid)
(not possible to put Polyurethane like thick GEMs(covering of anode...))

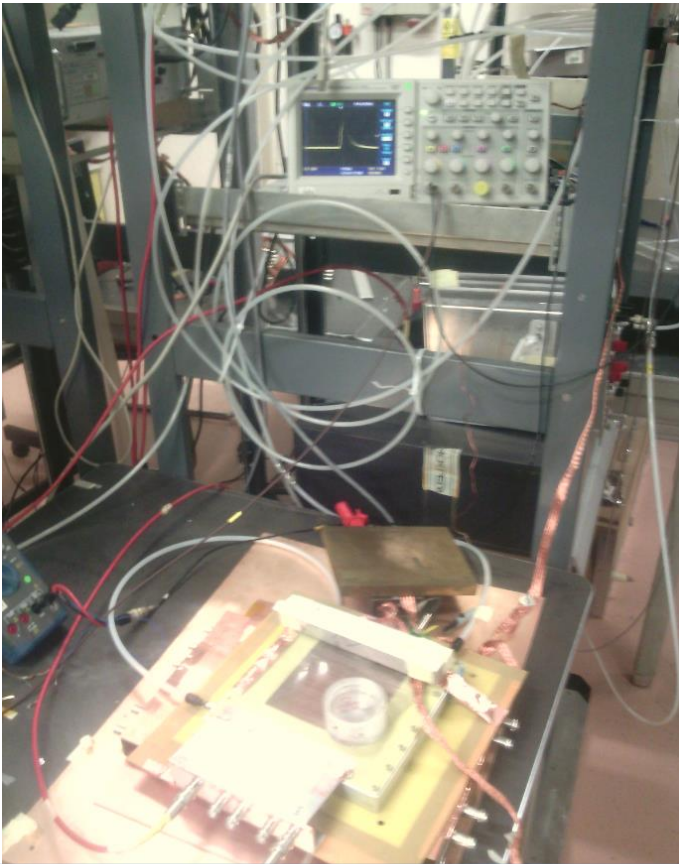
Detectors characterization

(Very preliminary results)

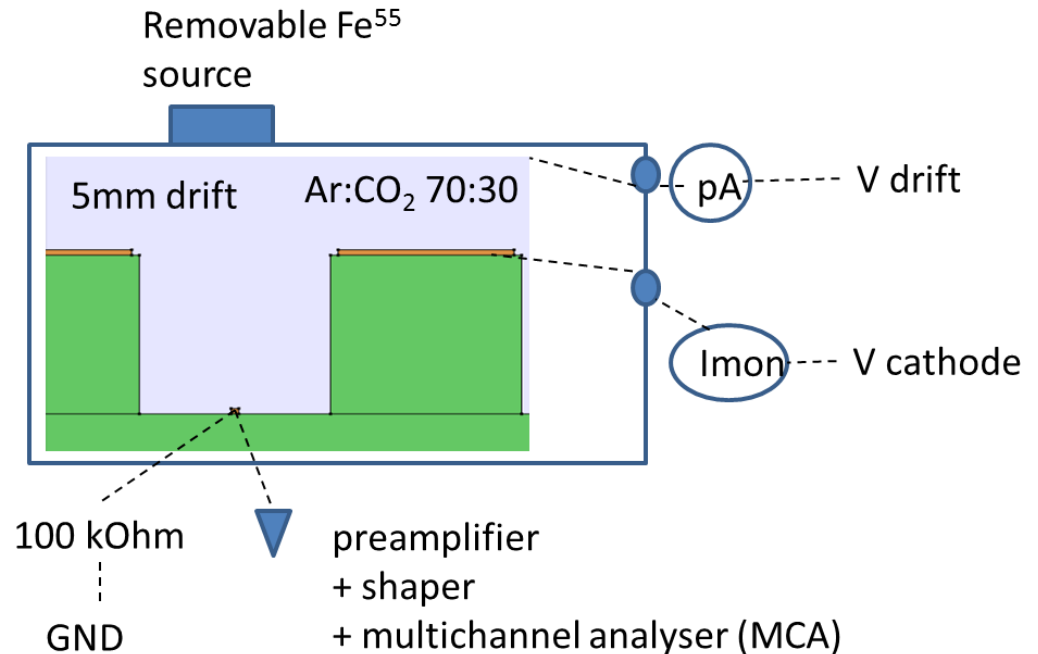
- Gain curves
- energy resolution
- uniformity



Experimental setup



Many thanks to the CERN
GDD lab support

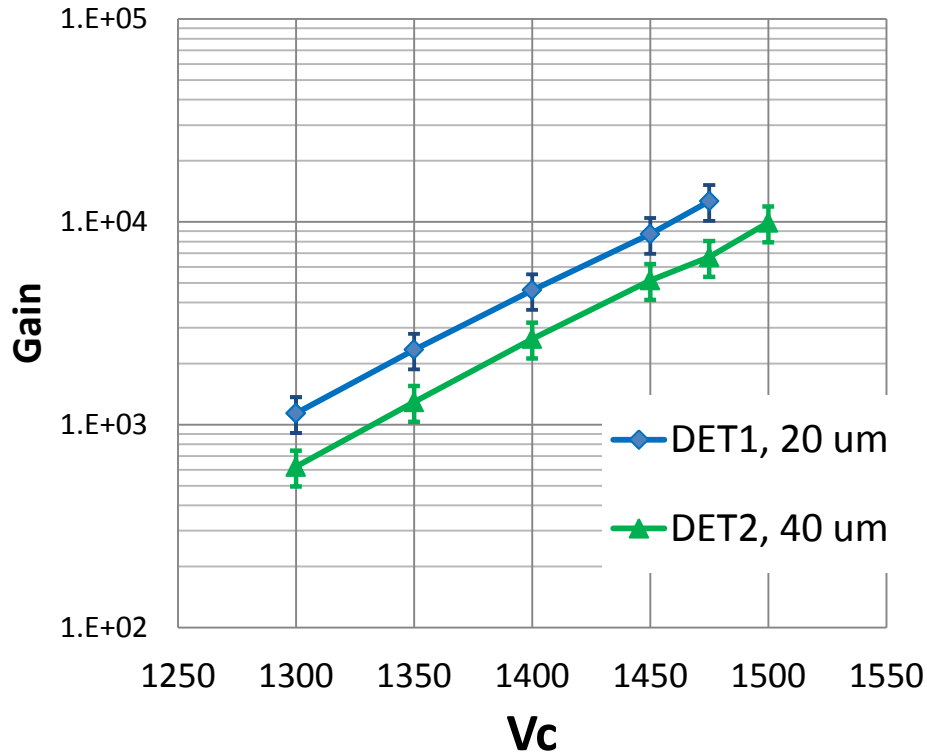


- Reading all anodes of same detector together
- Applied voltage on cathodes
- GND anodes

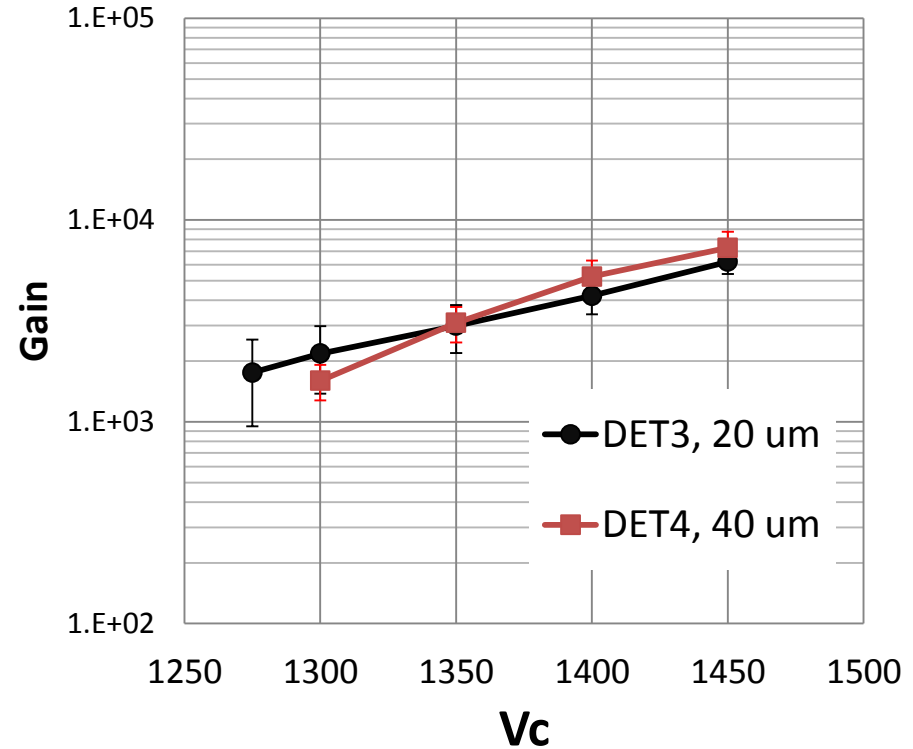
Gain curves

PRELIMINARY

gap 600, pillar 400



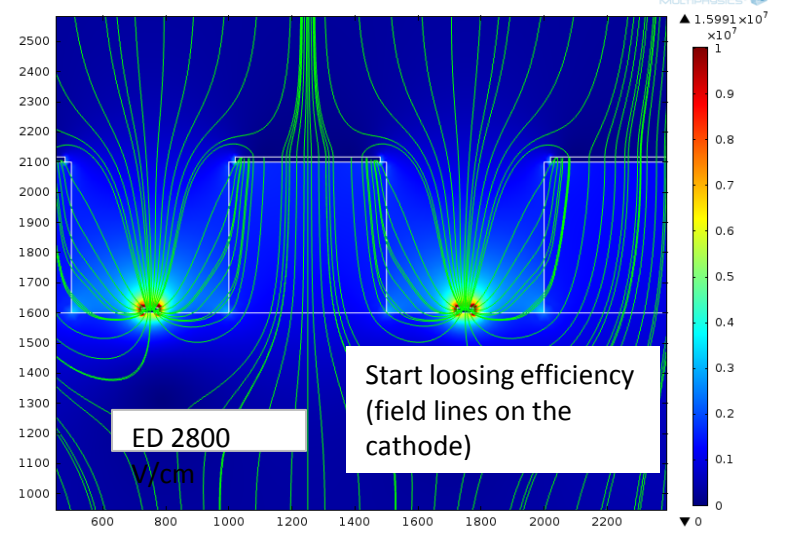
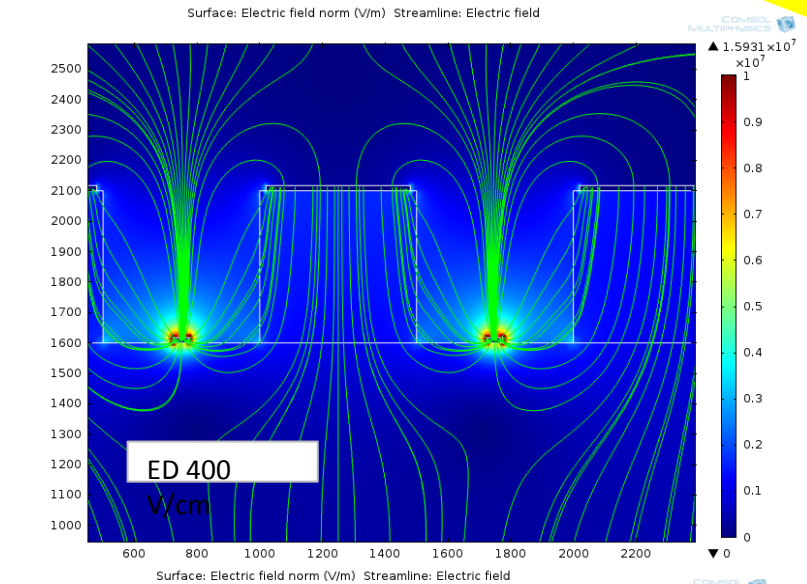
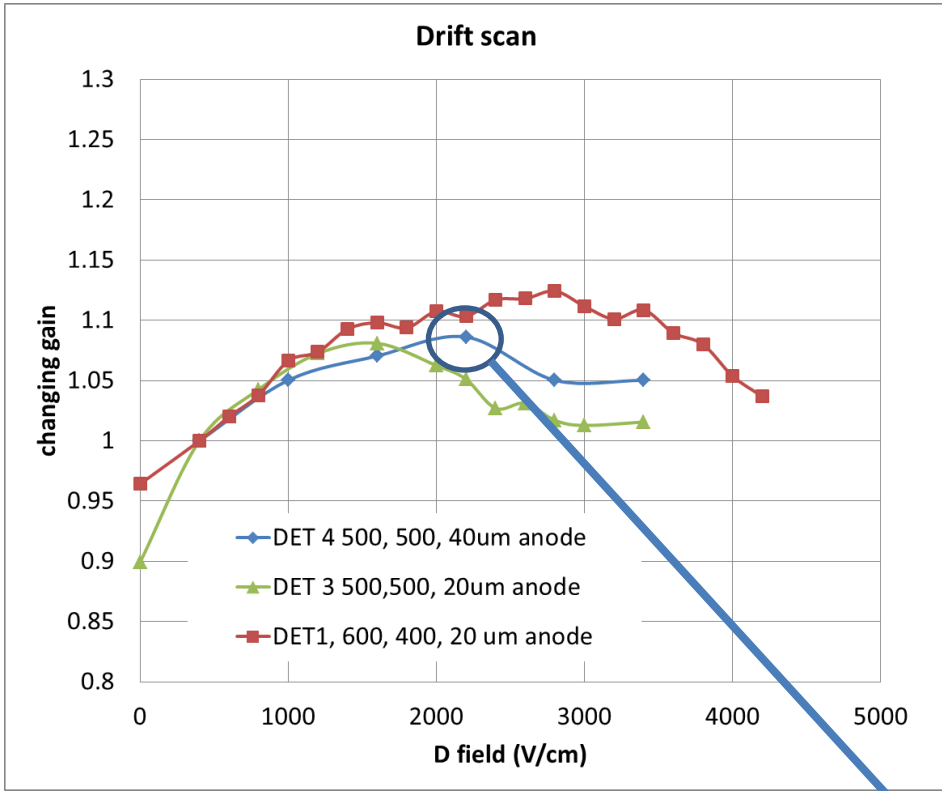
gap 500, pillar 500



- From preliminary tests not possible to go higher than 10^4 with gain
- Frequent sparks (1 spark/min) on last points of gain curve
- Needed at least $G \sim 5000$ for cosmic detection and stable operation (TO BE INVESTIGATED)

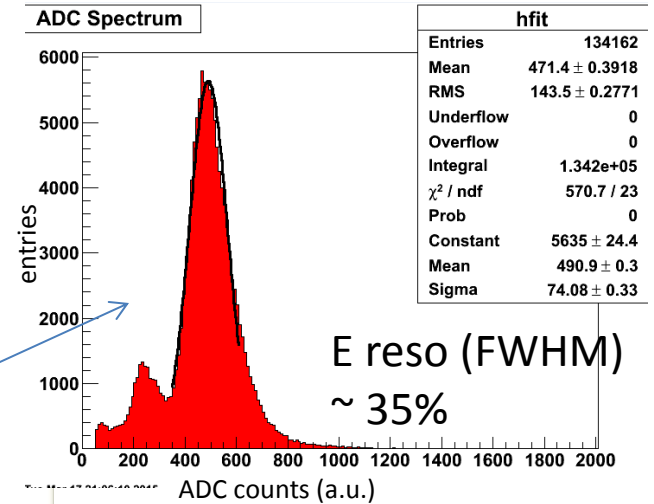
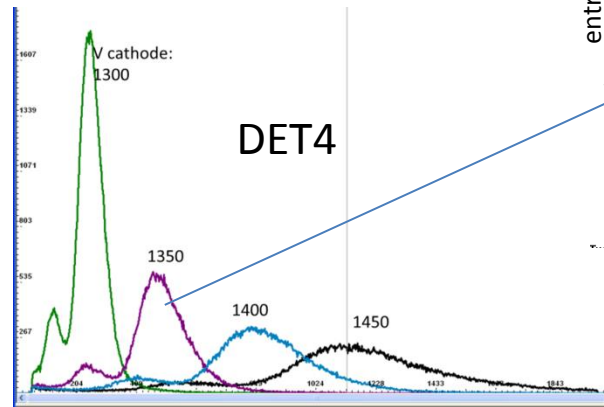
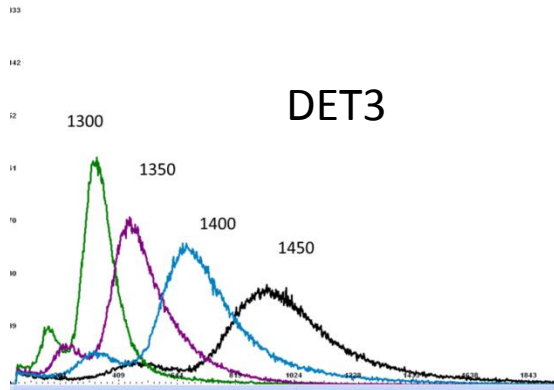
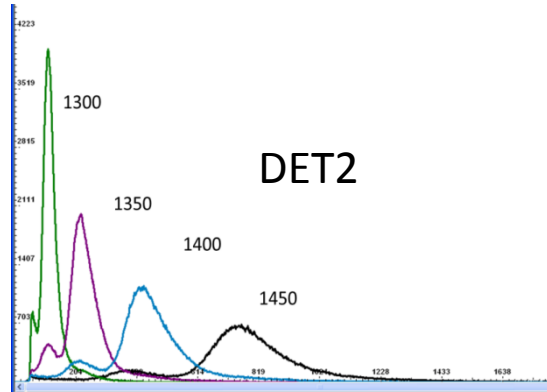
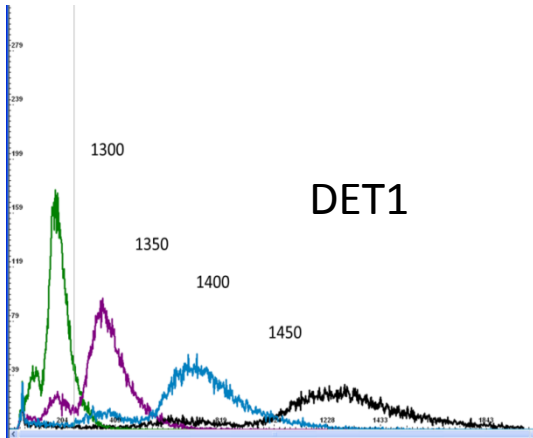
Drift scan

PRELIMINARY



Energy spectra

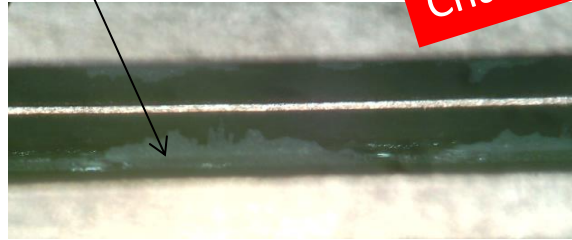
PRELIMINARY



As a common problem of MSGC, seen changings of gain vs time (charging up).
We are studying more carefully in order to evaluate the amount of this effect (work in progress)

Construction critical points

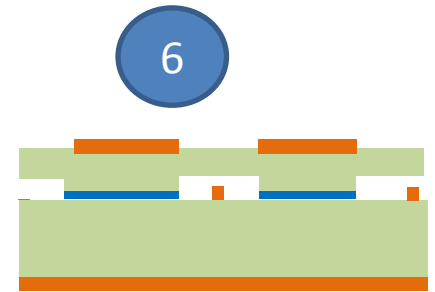
- **Alignment** (for next prototype need to insert more pillars in order to be sure no misalignment during pressing)
- **Glue flowing in amplification region**



Charging up

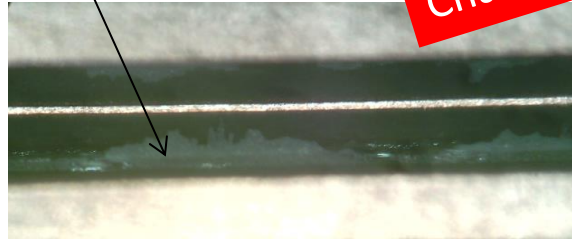


Pressing anode-cathode board



Construction critical points

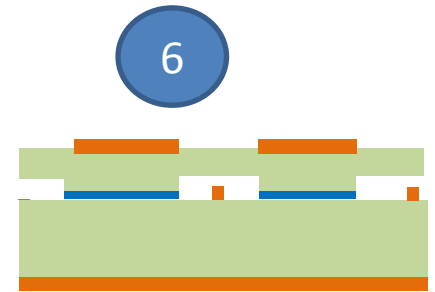
- **Alignment** (for next prototype need to insert more pillars in order to be sure no misalignment during pressing)
- **Glue flowing in amplification region**



Charging up

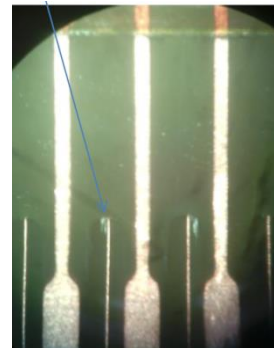


Pressing anode-cathode board

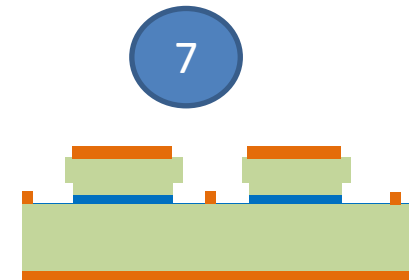


- **Machining of fiber glass**
Need to find a way of cleaning after milling (industry compatible)

Sparks



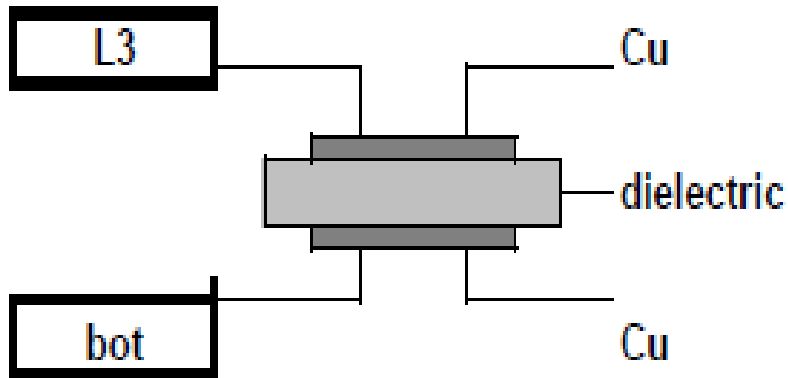
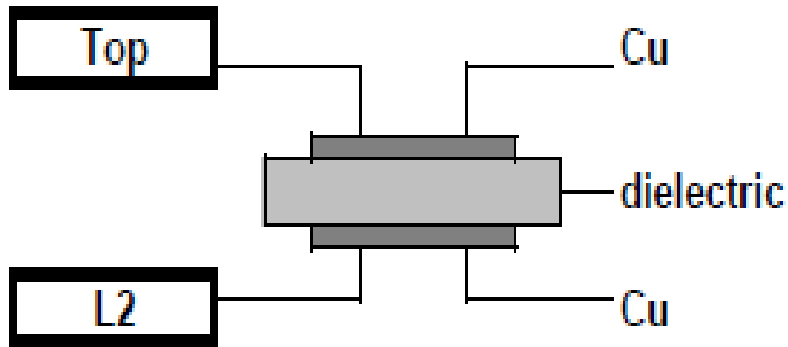
Milling of top face



Future plans

- Complete the first measurements
- Evaluate which of the four geometries is better in terms of sparks and gain stability
- Evaluate if detector is damaged by sparks (no resistive cathodes for first prototypes in order to be compatible with industrial production)
- Try other gas mixtures (e.g. Ar:CO₂ 93:7)
- Test in cosmic stand
- Chemical cleaning and retest (evaluate best procedure for cleaning, compatible with industrial production)
- Construction of new prototype (improving alignment and flowing of glue)
- Optimization of groove thickness and width

Backup



70

epoxy=emc

Thickness 0.5

0

krempe

2x25u

Thickness 0.05

35

epoxy =emc

Thickness 1.6

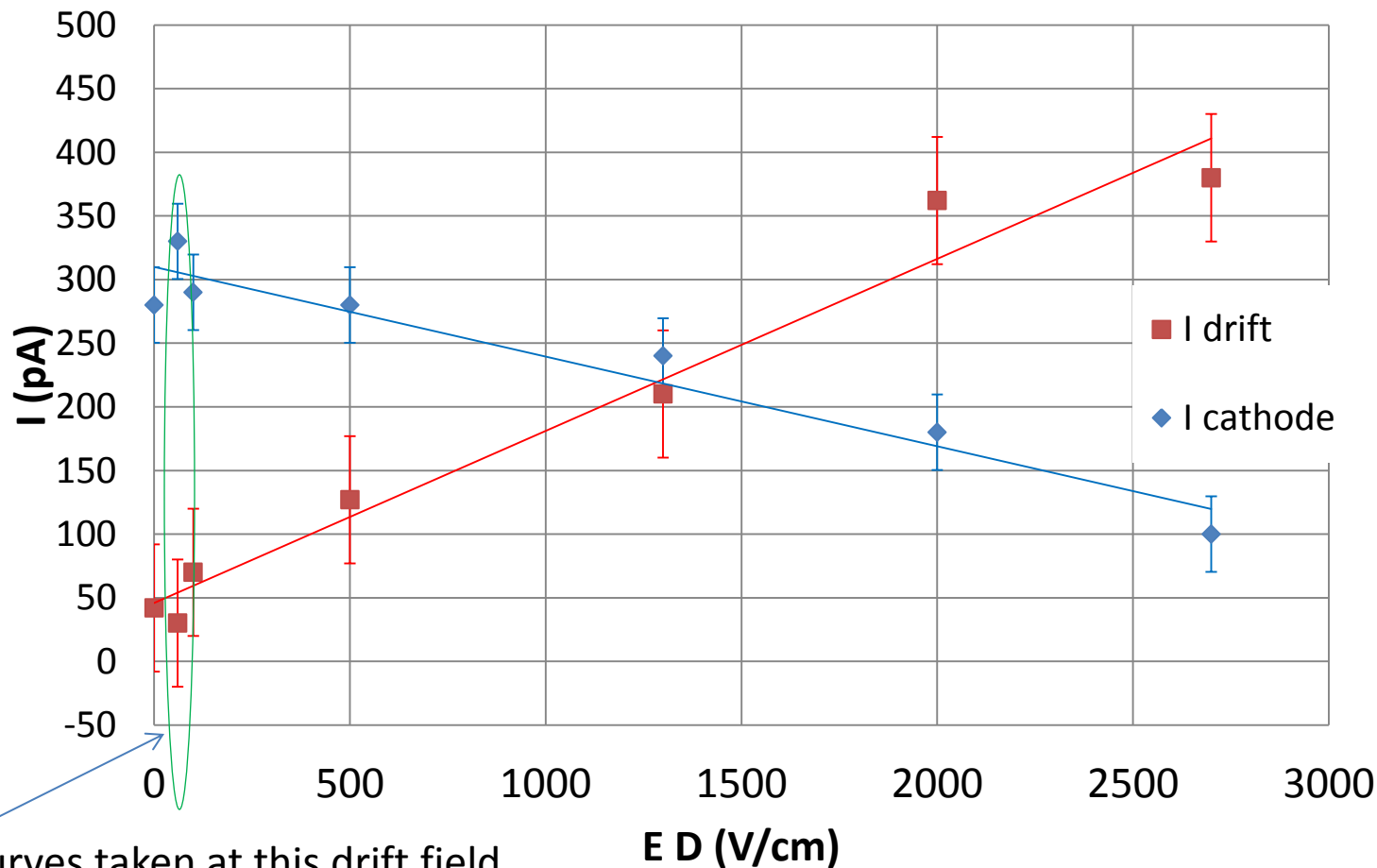
35

Det 4, Vc 1350 (G ~ 3000).

Changing the drift field and monitoring currents on cathode and drift (ion movements)

Higher D field, more ions sucked to the drift

Currents vs drift field, G ~ 3000



Gain curves taken at this drift field,
error on estimation of gain through
only I cathode ~ 10%

Chemical cleaning



Reduction of anode strips



Standard lithography process for anodes up to 40 μm width

Protection of half of anodes

Micro etching for 20 μm strips

Chromic acid bath

(etching time $\sim 1\mu\text{m}/\text{min}$)

Gain uniformity

